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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor(s) : Cecil C. Chappelow
Serial No. : 10/784,082
Filing Date : February 20, 2004
Title : PHOTOPOLYMERIZABLE COMPOSITIONS
THAT INCLUDE ALICYCLIC/AROMATIC
DIOXIRANES AND NOVEL DIOXIRANYL
TETRAOXASPIRO [5.5] UNDECANES

Group/Art Unit : 1714
Examiner : Not Yet Assigned
Confirmation No. : 7027

Atty. Docket No. : 800528.0015

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. § 1.97(b)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In accordance with 37 C.F.R. § 1.56 and § 1.97(b), the references listed below and on the attached Form PTO/SB/08A (Substitute for Form 1449A-B/PTO) are being brought to the attention of the Examiner for consideration in connection with the examination of the above-identified patent application. The present application is a divisional of prior application, Serial No. 10/091,791 filed March 5, 2002. The cited documents are already of record in the parent case, and therefore, copies are not being submitted with the present statement pursuant to 37 C.F.R. § 1.98(d). Submission of these references is not an admission that the references constitute prior art.

Certificate of Mailing Under 37 C.F.R. 1.8

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on:

Date: MAY 17, 2004
Signature: J. Barnard
Printed Name: Jessica V. BARNARD

The Director is hereby authorized to charge any additional amount required, or credit any overpayment, to Deposit Account No. 19-4409.

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Country	Patent No./Publication No.	Publication Date
None.		

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Sadhir et al., "Expanding Monomers: Synthesis, Characterization and Applications," CRC Press, Boca Raton, pg. 329-332, 1992.

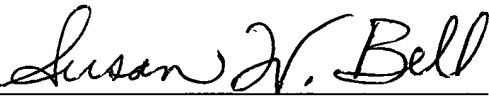
Applicant respectfully requests that these references be made of record in the above-identified application and considered by the Examiner during prosecution of the application.

It is respectfully submitted that the present invention as claimed is patentable over the listed references.

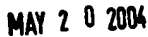
This information disclosure statement is being filed within three months of the filing date of a national application other than a continued prosecution application under § 1.53(d) or before the mailing of a first Office Action on the merits. Accordingly, no fee is due.

Acknowledgment of receipt is respectfully requested.

Respectfully submitted,

By: 

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Approved for use through 10/31/2002. OMB 0651-0031

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Substitute for Form 1449A/PTO

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

Complete if Known

Application Number:	10/784,082
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Filing Date:	February 20, 2004
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First Named Inventor:	Cecil C. Chappelow
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Group Art Unit:	1714
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Examiner Name:	Not Yet Assigned
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Attorney Docket Number: 800528.0015

U. S. PATENT DOCUMENTS

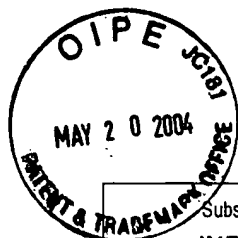
FOREIGN PATENT DOCUMENTS

Examiner
Signature

Date
Considered

¹Unique citation designation number. ²See attached Kinds of U.S. Patent Documents. ³Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶Applicant is to place a check mark here if English language Translation is attached.

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PTO/SB/08B (08-00)

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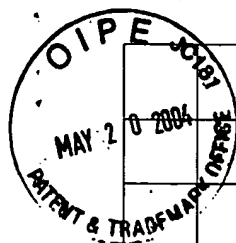
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Application Number:	10/784,082
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Group Art Unit:	1714
Examiner Name:	Not Yet Assigned
Attorney Docket Number:	800528.0015

Sheet 2 of 3

OTHER REFERENCES – NON PATENT LITERATURE DOCUMENTS AND INFORMATION

Examiner Initials*	Cite No.†	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T?
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